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Measurements of work function and negative Ion spectra from C12A7 electride immersed in a hydrogen plasma.

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ABSTRACT

The C12A7 electride attracts much attention as one of the possible plasma electrode material of Cs-free negative hydrogen isotope (H⁻/D⁻/T⁻) ion sources[1-2]. In this work, H-/D⁻ spectra from a C12A7 electride target immersed in an ICP plasma was measured in the apparatus, Phisis[3]. The target was biased negatively against the electrically grounded chamber. The temperature of the target was controllable up to 800 C. Negative ions were energy analyzed by a Hiden EQP300 mass spectrometer. By rotating the target, it can be irradiated by an energy-tunable photon beam, Omni Lamda 300i[4], when the plasma off, and the photo-electric current was measured. The work function of the sample can be obtained from the threshold photon energy. The lowest value of the work function observed was ~2.5 eV. This value was confirmed by UPS measurement with the similar conditioning procedure. Change of the negative ion yield due to the work function was measured.



probe

Target bias/current

A

Schematic diagram of the PYS (Photoelectron Yield Spectroscopy) experimental setup

The wavelength resolution at the lamp output is 6 nm when operating the monochromator with fully

opened slits. It limits the energy resolution to +/- 0.1 eV. The electrons are extracted from the sample using either a positively polarized external cylinder or by biasing it negatively using a -30V battery.

Work Function Measurement





Work function changes by annealing procedure, temperaature, plasma exposes (Ar, H₂, D₂), ion bombardment (Ar, H₂, D₂), UV irradiation (?), etc.



Step 1 ctly the same for H2 and D2. H2 campaign was carried out right after heating at 300 °C 20 minutes to clean the surface while D2 campaign was done after letting the sample under vacuum overnight (10^-8 mbar base pressure)

Step 2 : Argon plasma 120 eV 5 minutes cleaning procedure, same for both H2 and D2 campaign Step 3 : Exposed to the studied H/D Plasma without any bias.

For H2 : the work function is lowered to 2,6 eV. Again, we see the beneficial effect of exposing a non-biased electride sample to a H2 plasma. And again, two slopes for H2 measurements.

For D2 : the WF is lowered compared to step 2, showing that D2 has the same effect as H2 <u>Step 4</u>: WF measurements after applying a voltage to the sample (-10 V, -20V then -60 V) for NI measurements. For both cases, the last applied bias was -60 V, which correspond to 60 eV PI bombardment on the surface.

EXPERIMENTAL RESULTS : NEGATIVE ION YIELD



Negative Ion (H-/D-) counts measured in EQP 300. vs. work function measured by PYS. Peak counts are mostly contributed by Desorption by Scattering. The exponential dependence on the work function is weak, while the desorption conponents show slightly steeper tendency. The H/D difference can be explained as shown below



Concluding remarks

The work function close to 2.4 eV (as reported by Hosono et al.), was confirmed by UPS and PYS. Work function changes by annealing procedure, temperaature, plasma exposes (Ar, H₂, D₂), ion bombardement (Ar, H₂, D₂), and probably UV irradiation. The change shows an isotope effect. The exponential dependence on the work function is weak, while the desorption components show slightly steeper tendency. The H/D difference can be explained by incoming ion velocity. 18). [3] G. Ca